Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1768	438/694	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/02 17:02
L2	38	1 and (through-hole or (through adj hole)) and electrode	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/02 17:03
S1	4	"254858".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF -	2005/05/02 12:23
S2	0	2002-254858.pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 11:23
S3	10415	substrat\$3 with through\$3 with hol\$3 with electrod\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 13:40
S4	1	S3 with DRIE	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 12:28
S5	3015	S3 with semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 15:20
S6	25	S5 with Ion with Etching	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 14:05
S7	5164	substrat\$3 with through\$3 adj hol\$3 with electrod\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 12:31
S8	1129	S7 with semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/02 13:39

						
S23 6	0	"6864172.pn"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/05/04 11:36
S23 7	2	"6864172".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 12:56
S23 8	2	"6,790,775".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 13:09
S23 9	2	"6,239,495".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF .	2005/10/31 15:02
S24 0	565834	conductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:03
S24 1	243433	insulator	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:02
S24 2	171256	layer near metal	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:03
S24 3	8887	S240 and S241 and S242	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:03
S24 4	951	S243 and through near hole	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:03
S24 5	951	S243 and (through near hole)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:03

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S24 6	727	S245 and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:08
S24 7	3490	two near metal near layers	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:08
S24 8		S246 and S247	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:09
S24 9	10281	metal adj line	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:10
S25 0	3465	glue adj layer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:10
S25 1	129	S249 and S250	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:14
S25 2	. 86	S251 and plug	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:16
S25 3	361169	through adj hole	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:16
S25 4	36072	two near metal	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:16
S25 5	2200	S253 and S254	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:16

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S25 6	822	S255 and (plug or electrode)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:17
S25 7	124	S256 and S240 and S241	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:21
S25 8	2868250	via ,	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:21
S25 9	1293468	electrode	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:21
S26 0	3949369	S258 oe S259	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:21
S26 1	12335	metal adj lines	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:21
S26 2	8377	S260 and S261	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:21
S26 3	1561706	semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:22
S26 4	7182	S262 and S263	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:23
S26 5	24	damescene	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:26

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S26 6	3274560	conductor near electrode and (metal adj line) and glue layer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:28
S26 7	3274560	(conductor near electrode) and (metal adj line) and glue layer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:28
S26 8	1	(conductor near electrode) and (metal adj line) and (glue adj layer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:31
S26 9	14582	metal near insulator	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:33
S27 0	9420	insulator near substrate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:33
S27 1		S269 near S270	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:36
S27 2	5503	conductive near plug	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:36
S27 3	8	S272 near insulator	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:38
S27 4	0	S273 near (metal adj line)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR .	OFF	2005/10/31 15:36
S27 5	4849	metal adj ball	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:38

S27 6	361169	through adj hole	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:38
S27 7	. 9	S275 near S276	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:43
S27 8	230705	interconnect	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:45
S27 9	4571	through near S278	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:49
S28 0	64955	S240 and S241	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:49
S28 1	376	S279 and S280	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:53
S28 2	21067	ball adj grid	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:54
S28 3	4296	S282 and S278	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:54
\$28 4	245733	1and S241	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:55
S28 5	64955	S240 and S241	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/31 15:55

S28 6	258	S283 and S285	US-PGPUB; USPAT;	OR	OFF	2005/10/31 15:55
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			DERWENT;			
			IBM_TDB			